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 (US).</p> | <p>(74) Agents: AMII, Lisa, A. et al.; Morrison & Foerster LLP,
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- (54) Title:** COMPRESSED GAS CYLINDER WITH AN INTEGRAL VALVE

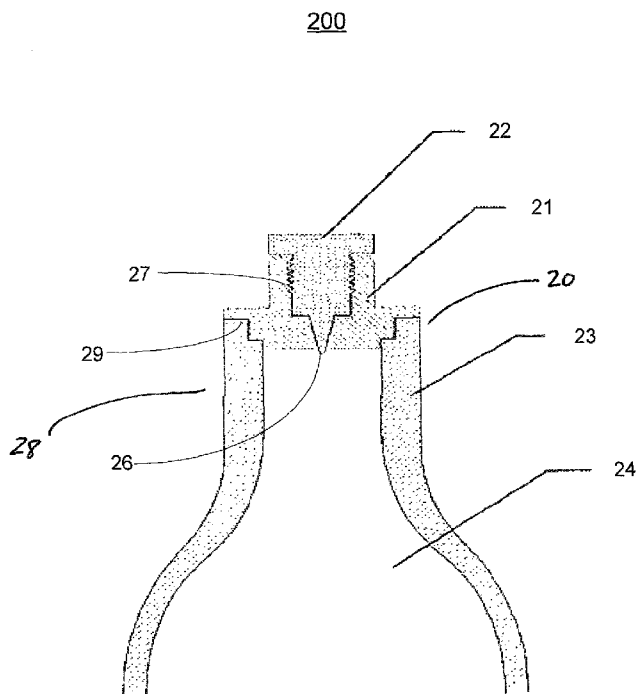


Figure 2

- (57) Abstract:** Described here are devices including gas cylinders for use in various applications. The applications may comprise the dispensing and administration of a compressed gas to the nasal mucosa of a user. The devices generally include an integral valve comprised of a valve seat and a valve pin. The orifice of the valve seat may be configured to limit the flow rate of the gas.

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